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# Toxic gases molecules (NH<sub>3</sub>, SO<sub>2</sub> and NO<sub>2</sub>) adsorption on GeSe monolayer with point defects engineering

Yuliang Mao<sup>†a</sup>, Linbo Long<sup>a</sup>, Jianmei Yuan<sup>†b</sup>, Jianxin Zhong<sup>a</sup>, Hongquan Zhao<sup>c</sup>

a. Hunan Key Laboratory for Micro–Nano Energy Materials and Devices, School of Physics and Optoelectronic, Xiangtan University, Hunan 411105, China.

b. Hunan Key Laboratory for Computation and Simulation in Science and Engineering, School of Mathematics and Computational Science, Xiangtan University, Hunan 411105, China.

c. Chongqing institute of Green and Intelligent Technology, Chinese Academy of Sciences, Chongqing 401120, China

<sup>†</sup> Corresponding authors, E-mail address: ylmao@xtu.edu.cn, yuanjm@xtu.edu.cn

## Abstract

First-principles calculations are performed to study the structure, stability, density of states and work function of toxic gases (NH<sub>3</sub>, SO<sub>2</sub> and NO<sub>2</sub>) molecules adsorption on GeSe monolayer with point defect engineering, including Ge/Se mono-vacancy, anti-site defect, and P atom substituted defect. Our results on the adsorption energy, charge transfer and electron localization function show that the interaction between gas molecules and point defects in GeSe monolayer is sensitive, which causes significant modification to the electronic structure and work functions of GeSe monolayer.

**Keywords:** monolayer GeSe; point defect; first-principles; work function

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